



IPW

IN THIS UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Charles Dennison

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Art Unit: 2818

Serial No.: 10/652,631

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Examiner: Quoc Dinh Hoang

Filed: August 29, 2003

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Docket: ITO.0539D1US
P10144D

For: Lower Electrode Isolation
in a Double-Wide Trench
and Method of Making Same

§

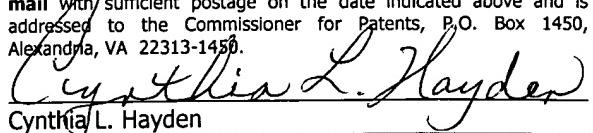
Assignee: Intel Corporation

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO PAPER NO. 1204

Sir:

In response to the office action mailed December 21, 2004, please amend the above-referenced patent application as follows:

Date of Deposit: February 28, 2005
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Cynthia L. Hayden